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Dated: September 28, 2004 Signature: [Signature]

(Michael R. Hum)

09884313

CofC

Docket No.: 30205/37456
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Letters Patent of:
Geun-Su Lee et al.

Patent No.: 6,770,415 B2

Issued: August 3, 2004

For: PHOTORESIST POLYMER FOR TOP-
SURFACE IMAGING PROCESS BY
SILYLATION AND PHOTORESIST
COMPOSITIONS CONTAINING THE SAME

Certificate
OCT 06 2004
of Correction

REQUEST FOR CERTIFICATE OF CORRECTION
PURSUANT TO 37 CFR 1.322

MS Post Issue
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Upon reviewing the above-identified patent, Patentees noted typographical errors which should be corrected.

Title Page
Column 1
Line 5
Field (*) Notice:

Please insert --This patent is subject to a terminal disclaimer--.

Support for this correction can be found in the Terminal Disclaimer filed February 19, 2003.

In the Claims:

Claim 1,
Column 9, Line 3 Please delete "1;" and replace with --1:--.

Support for this correction can be found at page 2, claim 1, line 2, of the Applicant's Amendment filed February 20, 2004.

OCT 08 2004

Claim 1,
Column 9, Line 18 Please delete "wherein, X₁ and X₂ are independently from the" and replace with --wherein, X₁ and X₂ are independently selected from the group consisting of--.

Support for this correction can be found at page 2 , claim 1, line 3, of the Applicant's Amendment filed February 20, 2004.

Claim 1,
Column 9, Line 20 Please delete "comprising an ether linkage;" and replace with --or alkylene comprising an ether linkage;--.

Support for this correction can be found at page 2 , claim 1, line 5, of the Applicant's Amendment filed February 20, 2004.

Claim 1,
Column 9, Line 21 Please delete "Y" and replace with --R--.

Support for this correction can be found at page 2 , claim 1, line 6, of the Applicant's Amendment filed February 20, 2004.

Claim 1,
Column 9, Line 22 Please delete "R" and replace with ----n--.

Support for this correction can be found at page 2 , claim 1, line 7, of the Applicant's Amendment filed February 20, 2004.

Claim 2,
Column 9, Line 27 Please delete "avid" and replace with --acid--.

Support for this correction can be found at page 2 , claim 2, line 2, of the Applicant's Amendment filed February 20, 2004.

Claim 2,
Column 9, Line 31 Please delete "methyletlayl," and replace with --methylethyl,--.

Support for this correction can be found at page 2 , claim 2, line 4, of the Applicant's Amendment filed February 20, 2004.

Claim 2,
Column 9, Line 32 Please delete "ten-butoxyethyl," and replace with
--tert-butoxyethyl,--.

Support for this correction can be found at page 2 , claim 2, line 5, of the
Applicant's Amendment filed February 20, 2004.

Claim 3,
Column 9, Line 35 Please delete "a" and replace with --n--.

Support for this correction can be found at page 2 , claim 3, line 1, of the
Applicant's Amendment filed February 20, 2004.

Claim 9,
Column 10, Line 6 Please delete "phthalimidotrifluoro-methane" and
replace with --phthalimidotrifluoro-methane--.

Support for this correction can be found at page 3 , claim 9, line 3, of the
Applicant's Amendment filed February 20, 2004.

Claim 10,
Column 10, Line 15 Please delete "inflate," and replace with --triflate,--.

Support for this correction can be found at page 3, claim 10, line 5, of the
Applicant's Amendment filed February 20, 2004.

Claim 10,
Column 10, Line 17 Please delete "hexafluoroarsenate" and replace with
--hexafluoroarsenate--.

Support for this correction can be found at page 3 , claim 10, line 6, of the
Applicant's Amendment filed February 20, 2004.

Claim 11,
Column 10, Line 22 Please delete "photo acid" and replace with --photoacid--.

Support for this correction can be found at page 3 , claim 11, line 2, of the
Applicant's Amendment filed February 20, 2004.

Claim 12,
Column 10, Line 29 Please delete "end" and replace with --and--.

Support for this correction can be found at page 3, claim 12, line 4, of the Applicant's Amendment filed February 20, 2004.

The errors were not in the application as filed by applicants; accordingly no fee is required.

Transmitted herewith is a proposed Certificate of Correction effecting such amendment. Patentees respectfully solicit the granting of the requested Certificate of Correction.

Applicants believes no fee is due with this request. However, if a fee is due, please charge our Deposit Account No. 13-2855, under Order No. 30205/37456 from which the undersigned is authorized to draw.

Dated: September 28, 2004

Respectfully submitted,

By

Michael R. Hull

Registration No.: 35,902

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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO. : 6,770,415 *132*
DATED : August 3, 2004
INVENTOR(S) : Geun-Su Lee et al.

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

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Column 1
Line 5
Field (*) Notice:

Please insert --This patent is subject to a terminal disclaimer--.

In the Claims:

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Claim 1, Column 9, Line 21	Please delete "Y" and replace with --R--.
Claim 1, Column 9, Line 22	Please delete "R" and replace with ----n--.

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Page 1 of 2

PATENT NO. 6,770,415 *132*

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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

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DATED : August 3, 2004
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Claim 2, Column 9, Line 27	Please delete "avid" and replace with --acid--.
Claim 2, Column 9, Line 31	Please delete "methyletlayl," and replace with --methylethyl,--.
Claim 2, Column 9, Line 32	Please delete "ten-butoxyethyl," and replace with --tert-butoxyethyl,--.
Claim 3, Column 9, Line 35	Please delete "a" and replace with --n--.
Claim 9, Column 10, Line 6	Please delete "phthalimidotrifluoxo-methane" and replace with --phthalimidotrifluoro-methane--.
Claim 10, Column 10, Line 15	Please delete "inflate," and replace with --triflate,--.
Claim 10, Column 10, Line 17	Please delete "hexafluoroansenate" and replace with --hexafluoroarsenate--.
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Claim 12, Column 10, Line 29	Please delete "end" and replace with --and--.

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